- 2 1. (previously presented) A light source (1) comprising
- 3 a discharge vessel (2) which is filled with a filling gas,
- 4 an electron beam source (4) arranged in vacuum or in a region of low pressure, which
- source (4) generates electrons (12) and propels them through an inlet foil (8) into the
- 6 discharge vessel (2),
- 7 characterized in that the inlet foil (8) comprises a diamond layer.
 - 2. (previously presented) A light source as claimed in claim 1, characterized in that the diamond layer has a thickness below $100 \, \mu m$.
 - 3. (previously presented) A light source as claimed in claim 1, characterized in that the diamond layer has a frame (7).
 - 4. (previously presented) A light source as claimed in claim 1, characterized in that the diamond layer has a metal brazing layer.
 - 5. (previously presented) A light source as claimed in claim 1, characterized in that the diamond layer has an organic adhesion layer.
 - 6. (original) A light source as claimed in claim 1, characterized in that the electron beam source comprises a thermionic electron emitter.

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- 7. (original) A light source as claimed in claim 1, characterized in that the electron beam source comprises a field emitter.
- 8. (original) A method of manufacturing a foil (8) for a light source (1), characterized by
- the following process steps:
- 3 carbon atoms are deposited on a substrate (7) so as to form a diamond foil (8), and
- a portion of the substrate is etched away such that a remaining portion (7) of the
- substrate forms a frame (7) for the diamond foil (8).
- 9. (original) A method of manufacturing a foil (8) for a light source (1), characterized by
- the following process steps:
- 3 carbon atoms are deposited on a substrate so as to form a diamond foil (8),
- 4 the diamond foil (8) is removed from the substrate, and
- 5 the diamond foil (8) is brazed to a frame (7).
- 10. (original) A method of manufacturing a foil (8) for a light source (1), characterized by
- the following process steps:
- 3 carbon atoms are deposited on a substrate so as to form a diamond foil (8),
- the diamond foil (8) is removed from the substrate (7), and
- 5 the diamond foil (8) is adhered to a frame (7).
- 11. (previously presented) A gas discharge lamp (1) comprising

- 2 a discharge vessel (2) which is filled with a filling gas, which vessel is adapted to produce
- non-coherent visible light from at least one wall in response to received radiation
- 4 produced by the gas;
- 5 an inlet foil comprising a diamond layer;
- 6 an electron beam source (4) arranged in vacuum or in a region of low pressure, which
- source (4) generates electrons (12) and propels them through the inlet foil (8) into the
- 8 discharge vessel (2), causing the gas to produce the radiation.
- 1 12. (previously presented) A method of manufacturing a light source, comprising, not
- 2 necessarily in the following order:
- 3 providing
- a discharge vessel (2) which is filled with a filling gas, which vessel is adapted to
- 5 produce non-coherent visible light from at least one wall in response to received
- 6 radiation produced by the gas
- an electron beam source (4) arranged in vacuum or in a region of low pressure,
- which source (4) generates electrons (12) and propels them into the discharge vessel
- 9 (2), causing the gas to produce the radiation;
- inserting an inlet foil between the source and the vessel, which inlet foil comprises a
- 11 diamond layer.
 - 13. (previously presented) The method of claim 12, wherein the light source is a gas discharge lamp.

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14. (previously presented) The light source of claim 2, wherein the diamond layer has a thickness below $50\mu m$.

15. (previously presented) The light source of claim 2, wherein the diamond layer has a thickness below $20\mu m$.

16. (new) The light source of claim 7, wherein the field emitter comprises carbon nanotubes for widening the electron beam.